Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	1	("5628917").PN.	USPAT	OR	OFF	2005/07/18 17:23
S2	50	("5628917").URPN.	USPAT	OR	ON	2005/07/18 15:41
S3	84	(comb with actuator) and oxidiz\$4 and etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:36
S4	6	(("5198390") or ("5536988") or ("5628917") or ("5770465") or ("6000280") or ("6073484")).PN.	USPAT	OR	OFF	2005/07/18 17:24
S5	6033	(microelectromechanical or micromechanical or MEMS or (mechanical with structure)) and oxidiz\$4 and etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:39
S6	5574	S5 and (width or thick\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:40
S7	5531	S6 and (level or floor or surface)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:41
S8	4874	S7 and silicon	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:41
S9	752	S8 and isotropic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/18 17:41
S10	598	438/712.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/11 14:20
S11	600	438/770.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/11 15:17

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	855	((line or structure or pillar or pattern or wall) and (variable or different) and (width or thickness) and oxid\$6 and etch\$4).CLM.	US-PGPUB	OR	ON	2005/12/11 16:25
L2	30	((line or structure or pillar or pattern or wall) and (variable or different) and (width or thickness) and oxid\$6 and (thin\$3 with full or complete) and etch\$4).CLM.	US-PGPUB	OR	ON	2005/12/11 16:29
L3	2	((line or structure or pillar or pattern or wall) and (variable or different) and (width or thickness) and oxid\$6 and (thin\$3 with (full or complete)) and etch\$4).CLM.	US-PGPUB	OR	ON	2005/12/11 16:31
L4	2	((line or structure or pillar or pattern or wall) and (variable or different) and (width or thickness) and oxid\$6 and (thin\$5 with (full or complete)) and etch\$4).CLM.	US-PGPUB	OR	ON	2005/12/11 16:31
L5	3	((line or structure or pillar or pattern or wall) and (variable or different) and (width or thickness) and oxid\$6 and (thin\$5 with (full\$3 or complete)) and etch\$4).CLM.	US-PGPUB	OR	ON	2005/12/11 16:31